

18/031957

531 Rec'd PCT/PTC 22 JAN 2002

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: :  
MAIK WIEMER et al. :  
Serial No. :  
Filed: :  
For: METHOD FOR PRODUCING A :  
TORSION SPRING :

INFORMATION DISCLOSURE STATEMENT

Hon. Commissioner of Patents  
and Trademarks  
Washington, D.C. 20231

Sir:

In accordance with the duty to disclose information material to the examination of this application as set forth in 37 CFR 1.56, copies of the following publications are submitted herewith:

(1) Article: C. Kaufman et al., "Characterization of Material and Structure Defects on Micromechanical Scanners by Means of Frequency Analysis," Proceedings of Micro Materials, (1995), P443 ff;

(2) Article: J. Choi et al., "Silicon Angular Rate Sensor by Deep Reactive Ion Etching," Proceedings of the International Symposium on Microsystems, Intelligent Materials and Robots (Sendai, Japan, 1995), pgs. 29 through 32;

(3) German patent publication DE 28 18 106 (12/7/78);

(4) P. Enoksson et al., "A Silicon Resonant Sensor Structure for Coriolis Mass-Flow Measurements", Journal of

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Micromechanical Systems, Vol. 6, No. 2 (June 1997), pgs. 119 through 125;

(5) International patent application WO 96/38710 (12/5/96); and

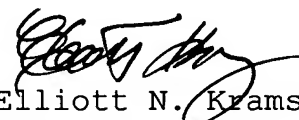
(6) German patent publication DE 41 26 100 (2/18/93).

Each of documents "1" through "5" was cited and its relevance to the claimed invention discussed within the body of International patent application PCT/EP 00/06957 filed July 20, 2000. The present application is the United States national stage of such application.

In addition, documents 3 and 5, along with document "6" were cited in the International Search Report issued November 21, 2000 in International patent application PCT/EP 00/06957. filed June 6, 2000. As set forth in the Search Report, each of

such references was cited as category "A" ("document defining the general state of the art which is not considered to be of particular relevance").

Respectfully submitted,



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